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Comparative Electron and Photon Excitation of Localized Surface Plasmon Resonance in Lithographic Gold Arrays for Enhanced Raman Scattering

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The ability to tune the localized surface plasmon resonance (LSPR) of nanostructures is desirable for surface enhanced Raman spectroscopy (SERS), plasmon-assisted chemistry and other nanophotonic applications. Although historically the LSPR is mainly studied by optical techniques, with the recent advancement in electron monochromators and correctors, it has attracted considerable attention in transmission electron microscopy (TEM). Here, we use electron energy loss spectroscopy (EELS) in a scanning TEM to study individual gold nanodiscs and bowties in lithographic arrays with variable LSPRs by adjusting the size, interspacing, shape and dielectric environment during the nanofabrication process. We observe the strongest Raman signal enhancement when the LSPR frequency is close to the incident laser frequency in Raman spectroscopy. A simplified harmonic oscillator model is used to estimate SERS enhancement factor (EF) from EELS, bridging the connection between electron and photon excitation of plasmonic arrays. This work demonstrates that STEM-EELS shows promise for revealing the contributions of specific LSPR modes to SERS EF. Our results provide guidelines to fine-tune nanoparticle parameters to deliver the maximum signal enhancement in biosensing applications, such as early cancer detection.

1 Introduction

2 The Raman signal from an organic molecule can be 3 significantly enhanced by its contact with a noble metal 4 surface1-3. This phenomenon, now known as surface 5 enhanced Raman spectroscopy (SERS), is employed in 6 biological and chemical sensing applications owing to its 7 high sensitivity and fingerprinting accuracy. Applications 8 range from single molecule sensing^{2,4}, rapid bacteria 9 identification⁵, artwork authenticity evaluation⁶ to the 10 detection of circulating tumor cells/DNA^{7,8} and early stage 11 tumors9-11. The latter has clear importance in cancer 12 diagnostics and therapy^{12–14}.

13 The SERS enhancement, which can be many orders of 14 magnitude, is generally recognized as mostly arising from 15 the local electric field enhancement associated with surface 16 plasmons in noble metals^{3,15}, which essentially are the 17 collective oscillation modes of the free electron gas at the 18 metal surface. Noble metal nanoparticles are particularly 19 useful as their localized surface plasmon resonance (LSPR) 20 energies are functions of nanoparticle parameters, such as 21 shape, size and mutual proximity¹⁶⁻²⁰. It is also expected 22 that greater enhancement (and so higher signal) would be 23 achieved when the induced plasmons are in resonance with

24 the illuminating photon energies^{21,22}.

25 While the LSPR of metallic nanoparticle clusters can be 26 studied by far-field extinction microscopy²³, far-field darkfield optical microscopy^{19,24} and near-field optical extinction 27 28 microscopy²⁵ techniques, their individual energies and local 29 distributions have been most effectively spatial 30 demonstrated by electron energy loss (EEL) mapping by 31 scanning transmission electron microscopy (STEM). 32 Nelayah et al.²⁶ first showed the plasmon distributions in 33 5.5 nm silver nanoprisms, which was expanded by Koh et 34 al.²⁷ to gold triangular combinations as fabricated by 35 electron beam lithography and to other nanoparticle shapes and sizes²⁸⁻³⁰. In the present work, we have used 36 37 lithographic methods to systematically vary the shape, 38 interspacing and size of nanoparticles, while studying their 39 effect on LSPR distributions using STEM-EELS. We then 40 compare the LSPR with the Raman signal enhancement 41 from the exact same areas and demonstrate experimentally 42 that the greatest Raman signal enhancement is obtained 43 when the LSPR energy matches that of the exciting laser or 44 Raman emissions. The quantitative experimental results on 45 individual nanoparticles obtained from EELS are consistent 46 with previous reported values on ensemble samples from 47 optical measurements and supported by the boundary 48 element method (BEM) simulations. Accordingly, we show 49 a method to roughly estimate Raman signal enhancement 50 factor (EF) using LSPR measured in EELS based on a 51 harmonic oscillator model, which can be practically used for 52 pre-screening plasmonic nanoparticles directly in TEM. Our

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Fig. 1 An overview of geometric parameters of gold nanodisc and bowtie arrays. (a) A schematic array of 30 nm thick Au nanodiscs on a 30 nm thick membrane substrate with the size and the spacing defined as the disc diameter and the edge-to-edge distance. (b) A schematic bowtie array with the triangle height as the bowtie size and the distance between two pointing vertices as the bowtie spacing. (c) Au nanostructures investigated in this work are: nanodisc arrays with diameter from 50 nm to 200 nm and interspacing from 35 nm to 160 nm; bowtie arrays with size from 70 nm to 200 nm and spacing from 20 nm to 180 nm. Insets are part of annular dark field STEM images of the nanodisc and bowtie arrays, with the gold structures being bright in these images. Additional images can be found in ESI Figs. 51, & S2.

53 observation when applying this method to bowties also 54 suggests that monochromated STEM-EELS shows promise 55 for revealing the contributions of specific LSPR modes to 56 SERS EF. By comparatively studying both electron and 57 photon excitation of surface plasmons, we propose a 58 procedure to engineer nanoparticles to precise shapes and 59 sizes to yield the highest Raman enhancement, which 60 would then be optimized for practical applications, such as 61 high sensitivity biomarker detection. This combination is 62 unique in our work. Additionally, the conclusions would also 63 benefit other fields utilizing LSPR enhancement, e.g. in solar 64 cells³¹, plasmonic nanoparticles with optimized parameters 65 would increase the absorption cross-section and overall 66 efficiency when the LSPR is fully excited by the incident 67 light.

68 Experimental

69 This work explores gold nanodiscs and bowties with 70 varying size and spacing, fabricated in 2 μ m × 2 μ m arrays 71 using electron beam lithography for fast prototyping. The 72 procedures have been described in a previous publication³². 73 The nanodisc size (diameter) and spacing (edge to edge 74 distance) ranged from 50-200 nm and from 35-160 nm, 75 respectively (Figs. 1a, & c). The bowtie size (triangle height) 76 and spacing (tip-to-tip distance) ranged from 70-200 nm 77 and from 20-180 nm, respectively (Figs. 1b, & c). Both 78 nanodiscs and bowties are 30 nm in thickness. Arrays were 79 fabricated on 35 nm thick SiN_x and SiO_x membranes to 80 enable examination with STEM. Additional details are given 81 in the Methods section. Nanoparticles with desired 82 properties can also be fabricated using scalable techniques, 83 such as optical based fabrication techniques³³ and wet 84 chemical synthesis.

85 During STEM-EELS measurements, a 300 kV electron 86 probe (approx. 0.5 nm diameter) was rastered across a 87 subset of the array (see Methods section for STEM 88 conditions) and EEL spectra were recorded simultaneously 89 at each pixel. Annular dark field (ADF) images of the 90 structures show contrast between different grain 91 orientations (Fig. 1c insets), indicating the structures are 92 polycrystalline. After EELS measurements, each array was 93 then tested with two different Raman dye molecules, 94 Rhodamine 6G (R6G) and 4-Mercaptopyridine (4-MP), in a 95 Raman confocal microscope with 532 nm, 638 nm and 785 96 nm wavelength lasers to collect Raman spectra from each 97 array.

98 Results and discussion

99 Nanodisc surface plasmons in EELS

100 First, we explore how plasmon excitation varies within a 101 single array (90 nm discs on SiN_x) as a function of electron 102 probe position. Experimental spectra, represented by solid 103 lines, were collected from the nanodisc perimeter (Fig. 2a), 104 in the midpoint between four discs (Fig. 2b) and at the disc 105 center (Fig. 2c). The zero loss peak (ZLP) is used to normalize 106 each spectrum to the same maximum intensity and 107 subsequently subtracted. Simulated EEL spectra, based on 108 the boundary elementary method³⁴, are plotted as dotted 109 lines in Figs. 2a, b & c and show good agreement with the 110 experimental data. These simulations utilized the 111 experimental electron beam energy and nanoparticle size,



Fig. 2 Localized surface plasmon peaks and the corresponding distribution of 90 nm discs on SiN_x in EELS mapping. EEL spectra (solid lines) and simulated spectra (dotted lines) are integrated from the disc perimeter **(a)**, the midpoint between discs **(b)** and the disc center **(c)**. Simulated charge density distributions are shown in the insets with points of excitation (e-beam locations) labelled correspondingly as blue, green and purple squares. Peaks at 1.9 eV all exhibit dipolar behavior, while the breathing mode (2.4 eV) is only present at the disc center. **(d)** Normalized EELS intensity distributions and **(e)** simulated maps at energy loss of 1.9 eV shows that the dipolar mode is omnipresent across the whole surveyed area but is strongest around the nanodisc perimeters. Maps at energy loss of 2.4 eV reveal that the breathing mode is restricted within the nanodisc center (strong intensities on bottom right of (d) 2.4 eV map is a result of a sharp spike at the edge possibly due to fabrication imperfection). Energy window of EELS maps is 0.01 eV.

112 and were calculated using models composed of nanodisc 113 arrays on a SiN_X or SiO_X substrate that were derived from 114 the real nanostructure geometries (more details in 115 Methods). Because of computational limitations, the 116 models were limited to nine disc arrays (one central disc 117 surrounded by its eight nearest neighbors), which was 118 sufficiently large to capture the experimental behavior. The 119 simulations were also used to predict the corresponding 120 surface charge density distributions at the LSPR peak 121 positions, as shown in the insets in Figs. 2a, b & c. A dipolar 122 surface plasmon mode at an energy loss of 1.9 eV, with 123 positive (red) and negative (blue) surface charges 124 distributed on the opposite sides of the disc, is present in all 125 three spectra. A breathing LSPR mode is present at 2.4 eV, 126 as indicated by the radial shape of charge density 127 distribution³⁵, and is only observed in Fig. 2c when the 128 electron beam is positioned at the disc center. However, a 129 plane wave illumination such as light cannot excite the 130 breathing mode because the symmetry of the charge 131 distribution results in a vanishing net dipole moment^{32,35}. 132 Therefore, this study will primarily focus on the dipolar 133 LSPR.

134 Once the energies of plasmon resonances have been 135 determined, we can plot the plasmon excitation intensity as 136 a function of position. Distributions at the dipolar mode 137 peak of 1.9 eV and the breathing mode peak of 2.4 eV are 138 shown in **Fig. 2d** with each pixel normalized to the ZLP 139 maximum and drawn to the same color scale.
140 Corresponding simulated EELS maps (Fig. 2e) show a similar
141 distribution and confirm that the dipolar plasmon mode is
142 omnipresent across the whole array with the most intense
143 peaks residing around the nanodisc perimeters, while the
144 breathing mode is only observed within the metallic
145 nanodiscs.

146 Effect of nanodisc parameters on LSPR

147 Several nanoparticle parameters, such as size, shape 148 and dielectric environment, have been studied theoretically 149 and experimentally that could affect LSPR^{15,20,36}. However, 150 a quantitative and systematic work studying the effect of 151 nanoparticle parameters on LSPR using EELS, compared 152 with SERS enhancement and supported by theory has not 153 been reported before to our knowledge. Experimental EEL 154 spectra from different diameter nanodiscs on SiN_x and SiO_x 155 membranes are summed within a 4 nm distance around the 156 nanodisc perimeters in Figs. 3a, & b. The measured dipolar 157 surface plasmon peak energies are plotted as a function of 158 nanodisc size from 30 nm to 220 nm in Fig. 3c. The 159 interspacing of the mentioned disc arrays is kept at 90 nm. 160 The LSPR energy blue shifts (as expected theoretically³⁷) as 161 the nanodisc size decreases, in a linear manner in this size 162 range and can be roughly estimated by (2.3 - 0.0037d) eV 163 for arrays on SiN_x and (2.6 - 0.0045d) eV for arrays on 164 SiO_x , where *d* is the disc diameter from 50 nm to 200 nm. 165 Therefore, nanoparticle size is an important parameter in 166 fine-tuning the localized surface plasmon response of the 167 nanostructure, as is the local dielectric environment. This 168 phenomenon has also been reported in various optical^{15,18} 169 and simulation³⁸ studies. Corresponding EELS simulations,



Fig. 3 Nanodisc size and dielectric constant of surrounding medium strongly affect LSPR energy. Integrated EEL spectra around the four discs perimeter showing surface plasmon peaks of various nanodisc size on **(a)** SiN_x (dielectric constant ~4.2) and **(b)** SiO_x (dielectric constant ~2.1) membrane, respectively. There is a clear blue shift (increasing peak energy) with decreasing disc diameter. Dotted lines are simulated EEL spectra of the corresponding nanodisc size in the same color scheme. The bold vertical dark line corresponds to a 785 nm (1.58 eV) laser excitation wavelength, the red line corresponds to a 638 nm (1.94 eV) laser excitation wavelength and the green line corresponds to a 532 nm (2.33 eV) laser excitation wavelength. The shaded area corresponds to the Raman spectra collection range from 550 cm⁻¹~1800 cm⁻¹ (0.068 eV ~ 0.22 eV). **(c)** Dipolar peak energies vary approximately linearly with nanodisc size from 30 nm to 220 nm measured in monochromated STEM-EELS. Error bars indicate the range of SPR energies in measured locations.



Fig. 4 Nanodisc spacing has a minor effect on LSPR energy and overall Raman signal enhancement. **(a)** Integrated EEL spectra around the nanodisc circumference in arrays at a constant diameter of 75 nm and various edge to edge separation from 35 nm to 160 nm on SiN_x membrane. Only a slight blue-shift (<0.2 eV) of the dipolar resonance energy when the separation is decreased indicates that interspacing has only a minor effect. **(b)** The corresponding Raman spectra of R6G from the same nanodisc arrays as in (a) measured with a 532 nm laser showing Raman signal enhancement is not strongly affected by the interspacing. The relatively lower Raman signal of 160 nm spaced nanodiscs may arise from a lower fill factor of nanodiscs in the array. The legend is the same as in (a).

170 represented by dotted lines in **Fig. 3a, b,** match the 171 experimental results well.

172 For the same size nanodiscs, we observe that the LSPR 173 energy is strongly dependent on local dielectric 174 environment. In the visible wavelength regime, the 175 dielectric constant for Si₃N₄ is ~4.2³⁹ and for SiO₂ is ~2.1⁴⁰. A 176 red shift of LSPR energy is shown in Fig. 3c when the 177 substrate dielectric constant increases because the 178 polarizability of the system, which is maximum at the 179 resonance frequency, is inversely related to both the 180 dielectric constants of nanoparticles and their surrounding 181 media¹⁵. A simplified model based on a quasi-static 182 approximation provides reasonable theoretical explanation 183 and can be found in ESI Fig. S3. This behavior is important 184 for biological applications as oftentimes plasmonic 185 nanoparticles are coated with functional and/or protective 186 layers (such as silica), which may have different dielectric 187 constants, affecting the resonance energy.

188 Interspacing is of interest due to a possible coupling 189 effect between localized surface plasmons in near field. EEL 190 spectra (Fig. 4a) around nanodisc edges in arrays at a 191 constant size of 75 nm and various interspacing from 35 nm 192 to 160 nm share similar shape and intensity. However, the 193 peak position is observed to slightly blue shift (< 0.2 eV) for 194 smaller interspacing due to the generation of bonding and 195 antibonding modes from LSPR hybridization and stronger 196 electrostatic repulsion of like charges²⁷. Significant 197 resonance shifts (> 1 eV) are observed in EEL spectra for 198 nanoparticles separated less than 3 nm due to quantum 199 tunneling effects⁴¹, but this is much lower than the range 200 studied here.

201

202 Effect of LSPR on Raman signal enhancement

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203 Raman spectra of R6G attached to different particle size 204 arrays were measured with a 532 nm (Fig. 5b, & S5b), a 638 205 nm (Fig. 5a, & S6) and a 785 nm laser (ESI Fig. S6a) at an 206 optimized power output (ESI Fig. S10). The 785 nm laser is 207 medically preferred due to a large tissue penetration 208 depth⁴², but clearly shows lower Raman signals for these 209 nanoparticles. The corresponding laser energies are also 210 labelled in Figs. 3a, & b as bold vertical lines at the positions 211 of 2.33, 1.94 and 1.58 eV, respectively. To the left of each 212 line, the shaded area represents the range of photon 213 energies collected by the Raman spectrometer. When the 214 excitation laser frequency is close to (and slightly higher 215 than) that of the LSPR of nanoparticles, the Raman signal 216 experiences a significant signal enhancement compared 217 with off-resonance situations. One such example is the 90 218 nm nanodiscs on SiN_x illuminated by a 638 nm laser (Figs. 219 **3a & 5a**), where the energy difference is less than 0.1 eV. 220 The other size arrays under the same illumination show less 221 enhancement as their LSPR energies deviate more from the 222 laser energy. Raman spectra for nanoparticles illuminated 223 by a 785 nm laser are mostly dominated by noise due to 224 inefficient surface plasmon excitation with a laser energy 225 much lower than the LSPR energy (ESI Fig. S6). When 226 illuminated by a 532 nm laser, the Raman signal is stronger 227 for smaller diameter arrays, again due to a smaller 228 difference between the laser and LSPR energy (ESI Fig. S6). 229 Raman spectra collected from samples on the SiO_x 230 membrane illuminated with a 532 nm (Fig. 5b) and a 638 231 nm laser (ESI Fig. S7) follow the same trend as described for 232 the SiN_x membrane samples. Raman spectra of nanodiscs 233 arrays with different interspacing (Figs. 4b & S5) do not



Fig. 5 Raman spectra of R6G attached to nanodisc arrays and comparison with estimated surface plasmon enhancement from EELS. Raman spectra from nanodiscs of different size on **(a)** SiN_x substrates measured with a 638 nm laser and **(b)** SiO_x substrates measured with a 532 nm laser. The highest Raman signal enhancement in (a) occurs for 90 nm diameter nanodiscs. The measured Raman signal enhancement factors (EF, as defined in Methods Equation (2)) at 611 cm⁻¹, 771 cm⁻¹, 1181 cm⁻¹ and 1361 cm⁻¹ from SERS (square marks) show good agreement with estimated G using Equation (1) above from EELS (triangle marks). For (b), the 75 nm and 55 nm discs enhance Raman signals better than the other arrays. Raman signal EF could not be properly quantified due to the lack of the control Raman spectra because R6G is highly fluorescent at 532 nm laser excitation.

Table 1. Experimental SERS EF of nanodisc and bowtie arrays tabulated from Fig. 5 and Fig. 7. Reported values of related studies are also included here.

Nanoparticles	Size (nm)	Separation (nm)	SERS EF $(\times 10^5)$	Misc.	References	
	55		0.5-0.9			
	75		0.8-1.6	R6G Raman dye,	This work.	
Au nanodisc arrays	90	/5	2.6-6	638 nm laser.		
	150	_	2.3-3			
Au periodic nanocylinders	200	25-100	0.25-0.8	pMA Raman dye, 785 nm laser	Gopinath et al.43	
Inverted Au nanodisc arrays	370	130	4.2	4-MP Raman dye, 785 nm laser	Yu et al.44	
	70		0.6-1.2		This work.	
Au bowtie arrays	100	20	4.0-8.9	R6G Raman dye,		
	140		3.3-5.1	038 mm laser.		
Au bowties	300	30	3.9	Theoretical work, EF derived from electric field enhancement.	Hrtoň et al.45	
Au bowties arrays	100	6	100	BPE Raman dye,	Zhang et al.46	
-		24	1	785 nm laser.	-	

show much variation in peak enhancement, which agreeswith their EELS measurements.

236 Although the observation may be regarded as intuitive, 237 the direct relation between the energy of surface plasmons 238 in EELS and the intensity of Raman signals has not been 239 explicitly shown before to our knowledge. Our observation 240 is also supported by previous work stating that there is no 241 significant spectral shift between the maxima of EELS and 242 optical extinction spectroscopy regarding surface 243 plasmons^{47,48}. However, it is reported that the maximum 244 near-field enhancements occur at lower energies than the 245 maximum of the corresponding far-field spectrum due to 246 the system damping in optical studies^{22,49}. We suspect 247 similarly lower resonance energy in EELS compared with 248 that in far-field optical measurements, but such a red shift 249 is negligible for the low damping systems investigated here. 250 Furthermore, in biosensing and other practical applications, 251 the maximum Raman signals might be achieved with a 252 lower energy laser than the LSPR energy of nanoparticles 253 due to the competition of extinction effects in solutions 254 against SERS enhancement⁵⁰, therefore one of the next 255 steps in our work would be to test the influence of various 256 liquid environments, first by Raman spectroscopy, and then 257 possibly by STEM-EELS using a liquid cell holder. In order to 258 scale up the nanoparticles for real applications, other 259 fabrication methods such as printing, lithography or 260 chemical synthesis, will need to be applied.

Another observation is that the Raman peaks are not enhanced uniformly. This is thought to be caused by the variation in local field enhancement at the frequency of different Raman emissions⁵¹. Following previous studies^{3,15}, the electromagnetic SERS enhancement G (a ratio of local field intensity at the nanoparticle array to that off the array) is defined by equation:

$$G = I_{Loc}(\omega_L) I_{Loc}(\omega_R) = \frac{|E_{Loc}(\omega_L)|^2}{|E_0(\omega_L)|^2} * \frac{|E_{Loc}(\omega_R)|^2}{|E_0(\omega_R)|^2}$$
(1)

268 where I_{Loc} is the local field enhancement at the laser 269 excitation frequency ω_L and the frequency of the Raman peak ω_R . It is safe to approximate $\omega_L = \omega_R^{15}$, yielding a 270 271 fourth-power dependency on local field at laser excitation frequency $G = \left(\frac{E_{Loc}}{E_0}\right)^4$. However, this approximation 272 273 breaks down at large wavenumbers, especially when the 274 laser energy is in the vicinity of the LSPR energy. The local 275 field enhancement would vary significantly even across a 276 relatively narrow spectrometer collection region. For the 277 150 nm disc array, although the LSPR energy (1.7 eV) is 278 lower than the 638 nm laser energy (1.9 eV), the 279 corresponding Raman modes in the range 1200 cm⁻¹ ~1600 280 $\rm cm^{\mathchar`-1}$ (tail of the red shaded area in Fig. 3a) are much closer 281 to the LSPR energy, therefore experiencing larger signal 282 enhancement than those in the range 600 cm⁻¹ ~800 cm⁻¹. 283 For the 90 nm size array, since the LSPR energy is close to 284 the 638 nm laser energy (Fig. 3a), smaller Raman shift peaks 285 exhibit stronger enhancement than those for the 150 nm 286 size array.

4-MP is also used as a probe molecule to characterize
the Raman signal enhancement in addition to R6G and the
results are summarized in ESI Fig. S8, & S9. The observed
trend on the same series of nanodisc arrays follows closely
those with R6G, suggesting that the enhancement provided
by the nanoparticles is independent on the type of Raman
dye.

294 There have been some works relating LSPR from EELS to 295 optical measurements. For example, Husnik et al.47 296 reported good agreement between the LSPR of gold 297 antennas measured in EELS and optical extinction 298 spectroscopy. Likewise, Křápek et al.48 compared EELS of 299 bowties fabricated by focused ion beam with extinction 300 spectra of EBL fabricated bowties and showed good 301 matching of LSPR energy for the transverse dipolar mode. 302 The direct link between light scattering and EELS of surface 303 plasmon excitations in metal spheres was also theoretically 304 demonstrated by modal decomposition³⁷. The uniqueness 305 of our work is that we incorporated the linewidth and



Fig. 6 Experimental EEL spectra of bowtie arrays and LSPR spatial distribution on ${\rm SiN}_{x\cdot}$ (a) EEL spectra at bowtie vertices (left column) and edges (right column) show dipolar (1.5-2 eV) and quadrupolar (2-2.5 eV) modes. The extraction points of EEL spectra are also marked as black squares on the simulated electron density distribution (calculated based on 100 nm bowties with a 50 nm gap), i.e. inner vertices and edge midpoints (dashed lines), as well as outer vertices and edge midpoints (solid lines). Surface plasmon excitation at the inner regions favors antibonding dipolar configuration while the outer regions tend to hybridize the bonding and antibonding dipolar modes (represented by a plus sign of two type electron distributions), resulting in a red-shift of 0.07-0.1 eV for outer dipolar peaks. The gap distance is 20 nm and the triangle height ranges from 70 nm to 140 nm. Simulation details are included in ESI Fig. 12. The bold vertical red line and shaded area correspond to the 638 nm (1.94 eV) laser excitation and the Raman spectra collection range from 550-1800 cm⁻¹ (0.07-0.22 eV), respectively. (b) Dipolar LSPR peak energies vary approximately linearly with bowtie size from 70 to 220 nm measured in EELS and the resonance energy is consistently lower with SiN_x substrates than SiO_x substrates for the same structures. (c) EELS intensity map of the 140 nm bowtie at energy loss of 1.6 and 2.1 eV, showing the distribution of the dipolar (left) and the quadrupolar modes (right).

intensity of EELS in addition to the plasmon peak positions
to correlate and estimate Raman signal enhancement,
which leads to a practical way of optimizing nanoparticle

309 parameters for maximum SERS enhancement.

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310 A damped harmonic oscillator model was successfully 311 implemented to describe the localized surface plasmon 312 response in both optical spectroscopy⁴⁹ and EELS⁵², given in 313 the simple form of a Cauchy-Lorentz distribution. The 314 plasmon induced local field enhancement I_{Loc} is essentially 315 the polarizability of the metallic nanostructure¹⁵, which can 316 be derived from the amplitude of the fitted Lorentzian 317 function⁴⁹. In combination with Equation (1), we roughly 318 estimated the SERS enhancement G based on the LSPR 319 energies of different nanodisc sizes, and compared them 320 with experimentally measured enhancement factors (EF) at 321 611 cm⁻¹, 771 cm⁻¹, 1181 cm⁻¹ and 1361 cm⁻¹ (Fig. 5a) using 322 Equation (2). EF and G are comparable in this study because 323 most enhancement comes from the electromagnetic field 324 interaction. The implementation details can be found in the Methods section. Within the same nanodisc array, the 325 326 estimated G for different Raman emissions follows closely 327 the experimentally measured EF. Our estimation for 328 different nanodisc sizes also reflects their relative Raman 329 peak intensities correctly. Although our model complies 330 with the trend from inter- and intra-array measurements, 331 certain deviations may be caused by (1) uncertainty of 332 Raman peak intensity due to noise and autofluorescence 333 background; (2) far off-resonance excitation as in the case 334 of 150 nm nanodiscs with 532 nm laser excitation. 335 Nonetheless, this simple model provides unique insights 336 into the Raman signal enhancement from EELS data. The 337 experimentally measured EF in Fig. 5a & 7a are tabulated 338 along with reported values of related studies^{43–45} (Table 1). 339 Our optimized nanodiscs show larger EF than the cited 340 highest values in the literature. The EF of our bowties are 341 also at the same level of reported values of similar 342 structures.

343 Comparison of bowtie arrays and nanodisc arrays

Bowtie arrays, comprised of two sets of equilateral triangles pointing towards each other (**Fig. 1b**), are expected to have stronger Raman enhancement due to the local field confinement and a "lightning rod effect"¹⁵. They



Fig. 7 Raman spectra and EF of bowtie arrays and comparison with nanodisc arrays. (a) R6G Raman spectra of different size bowties and their corresponding SERS EF collected using a 638 nm laser show similar enhancement behavior to that of nanodisc arrays. The estimated G using dipolar peaks from outer vertices is similar to that from outer edge midpoints due to relatively small changes in hybridization. The bonding and antibonding dipolar modes from the outer edge midpoint of 140 nm bowties are deconvolved (ESI. Fig. S13) and the estimated G from the bonding dipolar peak shows better fitting with the measured EF than the antibonding dipolar peak. R6G Raman spectra comparison of (b) 150 nm disc and 140 nm bowtie arrays and (c) 90 nm disc and 100 nm bowtie arrays illuminated with a 638 nm laser, shows stronger signal enhancement for bowtie arrays under the same collection conditions.

348 were fabricated directly on TEM grids in a similar fashion as 349 for the nanodisc arrays. Most findings from the latter are 350 applicable to bowtie arrays. For example, larger bowtie size 351 and support medium dielectric constant (Figs. 6a, & b) 352 result in lower LSPR energy, and the larger interspacing 353 between two pointing vertices has a small effect on red 354 shifting the LSPR energy (ESI Fig. S11). However, the 355 reduced symmetry of bowties (compared with discs) allows 356 multiple LSPR modes that can be excited by the electron 357 beam due to the delocalized response and beam broadening effects⁵³. Fig. 6a shows EEL spectra of different 358 bowtie sizes on SiN_{x} membranes, extracted from the 359 360 corresponding black square marked locations of the 361 simulated charge density map. The dipolar peaks from 362 outer regions (away from the gap, solid lines) are 363 approximately 0.07-0.1 eV lower than those from inner gap 364 regions (dashed lines) because of hybridization of bonding 365 and anti-bonding dipole configurations⁵⁴. At inner-gap 366 vertices only the anti-bonding dipolar mode is excited as 367 indicated by the electron density distributions^{27,55}. The peak 368 positions of bonding and antibonding dipolar modes of 140 369 nm bowties are spectrally visible at 1.54 and 1.64 eV 370 respectively (Fig. 6a) and subsequently fitted using two 371 Voigt functions (ESI Fig. S13). An additional transverse 372 dipolar mode at even lower energy is reported for focused-373 ion beam fabricated bowties comprised of right triangles 374 when excited at outer vertices⁴⁸, but not observed here due 375 to the symmetry of equilateral triangles. Interestingly, 376 nanodiscs and bowties of similar size also have roughly 377 similar LSPR energies (Fig. 3a, & 6a). Additional results on 378 dipolar LSPR energies as a function of bowtie size from 70 379 nm to 220 nm are plotted in Fig. 6b for structures on SiN_x 380 and SiO_x substrates. Just like nanodisc arrays, the LSPR 381 energy of the same structures is higher on the SiO_x than on 382 the SiN_x substrates due to the difference in dielectric 383 constants.

384 An additional mode at energy loss 2.0-2.5 eV in Fig. 6a 385 when excited at the midpoints of inner edges can be 386 attributed to a quadrupolar configuration²⁷. Fig. 6c shows 387 the spatial distribution of the dipolar LSPR mode (at 1.6 eV) 388 and dark quadrupolar LSPR mode (at 2.1 eV) in a 140 nm 389 bowtie extracted from an EELS spectrum image. These 390 results show that the strongest dipolar modes reside on 391 triangle vertices while the quadrupolar modes primarily reside along the sides of the bowties. More detailed 392 393 discussion of different plasmon modes in triangular arrays 394 can be found in the previous study by Koh et al.²⁷

The Raman enhancement behavior from dipolar surface plasmons is similar for both bowties and nanodiscs, as illustrated by the Raman spectra (**Fig. 7a**) collected using a 638 nm laser for different size bowties on a SiN_x substrate. 100 nm bowtie arrays have overall strongest signal enhancement due to close match between the incident laser energy and dipolar LSPR energy. The quadrupolar mode is believed to be a dark mode^{26,27} and thus should have insignificant effect on Raman signal enhancement (**ESI 404 Fig. S14**). The measured EF of four Raman emissions are also 405 plotted in Fig. 7a. Using the same damped harmonic 406 oscillator model, the calculated enhancement G based on 407 the less hybridized dipolar surface plasmon peaks on outer 408 vertices deviates away from the EF at small wavenumbers 409 (611 cm⁻¹), while it agrees better at large wavenumbers 410 (1361 cm⁻¹) compared with that based on the more 411 hybridized plasmons on the corresponding outer edge 412 midpoints for the 100 nm bowties. Overall, G from outer 413 vertices does not differ much from outer edge midpoints 414 due to relatively small changes in hybridization. However, a 415 preliminary estimation of G from the bonding dipolar mode 416 shows better agreement with experimentally measured EF 417 than that from the antibonding dipolar mode for 140 nm 418 sized bowtie arrays (Fig. 7a) based on the fitted peaks in ESI 419 Fig. S13 (details in Methods), suggesting that the bonding 420 dipolar mode is the dominant factor for enhancement 421 under the laser excitation. This is reasonable because the 422 antibonding mode is a dark mode and therefore would not 423 be efficiently excited with a laser. Besides, the electric field 424 in the gap is only strongly enhanced by the bonding dipole 425 mode, but not the antibonding mode⁵⁶. Hence, the 426 measured EF would mainly reflect bonding mode behavior. 427 Future studies can aim to further test the relation of SERS 428 EF and estimated G from antibonding dipolar, transverse 429 and longitudinal dipolar, and other surface plasmon modes 430 using higher energy resolution STEM-EELS and polarized 431 Raman spectroscopy on less symmetric nanostructures.

432 A rough comparison of Raman spectra between 433 approximately similar sized nanodisc and bowtie arrays 434 under the same illumination conditions (Fig. 7b, c) shows 435 higher signal enhancement for bowtie arrays due to the 436 stronger electric field near the sharp vertices, given that 437 their LSPR energy difference is small. Similar behavior is also 438 observed in other geometric configurations such as 439 plasmonic heterodimers for SERS hotspots⁵⁷, where the 440 separation gap is extremely small (< 5 nm). However, the 441 shape effect on Raman signal enhancement is weaker for 442 small size arrays (Fig. 6c) than that for large size arrays (Fig. 443 6b), possibly due to the decline of fabrication quality as nanostructure features become smaller. 444

445 Conclusions

446 In summary, we have systematically varied gold 447 nanoparticle size, interspacing and shape using electron 448 beam lithography fabrication, and showed that these 449 nanoparticle parameters as well as local dielectric 450 environment affect surface plasmon resonance. 451 Nanoparticle size plays the most important role in fine-452 tuning the resonance energy. Pointed structure shapes 453 have stronger field confinement and therefore strongly 454 enhance the Raman signal. By correlating LSPR energies 455 from EELS with Raman peaks from laser excitation, we 456 demonstrate that the Raman signal is most strongly 457 enhanced when the illuminating laser energy is close to and slightly higher than the LSPR energy, as in the case of 90 nm 458 459 nanodisc arrays measured with a 638 nm laser. Using

460 monochromated STEM-EELS, this study brings insight from 461 nanometer level spatial distribution of localized surface 462 plasmons to far-field surface enhanced Raman 463 spectroscopy. We anticipate that the techniques and 464 correlations demonstrated in this study will provide a set of 465 tools and guidelines to optimize Raman signal enhancement 466 in real applications such as nanomedicine for cancer 467 diagnostics and treatment^{11,13}.

468 Methods

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469 Nanostructure array fabrication

470 TEM grids with SiN_x and SiO_x membranes (Ted Pella Inc., 471 35 nm thick) were first plasma cleaned to remove potential 472 organic contaminants. They were then adhered to a piece 473 of silicon wafer using polydimethylsiloxane and spin coated 474 with 2% 950 kDa PMMA (E-beam resist) in anisole at 2500 475 rpm followed by baking for 5 min at 180 °C. The samples 476 were loaded near the center of a slot holder and a JEOL JBX 477 6300 E-beam lithography system (JEOL, Ltd, Japan) was 478 operated as a scanning electron microscope (SEM) to locate 479 the small electron transparent windows. To limit random 480 electron exposure on the patterning area, the stage 481 positions of two opposite corners of the grid were carefully 482 found to roughly calculate the coordinates of the grid 483 center. The lithography system was then switched to 484 pattern writing mode with a 100 kV 500 pA beam and an 485 average dose of 2000 μ C/cm². The overall pattern 486 resolution is approximately 9 nm. The patterns of nanodisc 487 and bowtie arrays with different size and spacing were 488 described in a proprietary format from JEOL and rendered 489 into exposable files using BEAMER software (GenISys 490 GmbH, Germany). After lithography, the samples were 491 submerged in a 1:3 methyl isobutyl ketone/2-propanol 492 solution for 30 s to selectively dissolve the patterned region 493 while keeping the remaining PMMA intact as a mask for 494 metallization. The samples were then rinsed in 2-propanol 495 and blown dry with compressed air. To avoid the damping 496 effect of a metallic adhesion layer, an organic alternative, 497 (3-mercaptopropyl) trimethoxysilane (MPTMS) was applied 498 by vapor deposition ³². Gold depositions were performed in 499 a Kurt J Lesker E-beam evaporator, and film thickness of 500 roughly 30 nm was reported by a crystal monitor. A lift-off 501 process was carried out in an acetone bath to strip away the 502 PMMA mask and leave only the Au in the patterned 503 (unmasked) region. Samples were rinsed in deionized water 504 and dried with compressed air.

505 Electron energy loss spectroscopy

506 STEM-EELS spectrum images were collected in an image 507 C_s corrected monochromated FEI Titan (Thermo Fisher 508 Scientific, USA) at 300 kV with a Gatan Image Filter (GIF) 509 Quantum (Gatan, Inc, USA) EEL spectrometer. The 510 microscope was operated in STEM mode at a spot size of 11 511 with a C2 aperture of 150 μ m and a C3 aperture of 50 μ m, 512 resulting in a convergence semi-angle of 8.4 mrad and an 513 estimated beam size of 0.5 nm in diameter. The GIF 514 Quantum was operated in EELS mode with a 2.5 mm 515 entrance aperture and a camera length of 38 mm 516 (corresponding to a collection angle of 18.3 mrad). EELS 517 maps were collected with a 2 nm pixel size and 0.01 518 eV/channel dispersion over a typical 100 × 100 array. The 519 full width at half maximum (FWHM) of the zero loss peak 520 (ZLP) was measured to be from 0.13 to 0.2 eV throughout 521 the experiments. Spectral collection time was selected to 522 maximize the signal without saturating the EELS detector, which is about 2 ms dwell time for this system. 523

524 Surface enhanced Raman spectroscopy

525 All samples were submerged in a 0.1 mg/mL aqueous 526 solution of Rhodamine 6G (R6G) or 4-mercaptopyridine (4-527 MP) overnight, rinsed in deionized water and blown dry 528 with compressed air. Raman spectroscopy was performed 529 on a Horiba XploRA+ system using a 100X objective lens to 530 focus the laser beam to the smallest possible spot (~2 μ m), 531 which is roughly the same as the nanostructure array size. 532 An output power of 0.6 mW for the 532 nm laser, 1.7 mW 533 for the 638 nm laser, and 8 mW for the 785 nm laser were 534 carefully chosen to avoid ablation (described in SI Fig. 7) 535 while still maintaining reasonable signal to noise ratio. 536 Spectral acquisition time was optimized accordingly, and 537 each spectrum was accumulated three times to reduce 538 noise and artifacts. Raman spectra were not normalized, 539 but the comparison was based on the same acquisition 540 conditions. The enhancement factor (EF, a ratio of surface 541 enhanced Raman intensity to the control sample Raman 542 intensity) for rhodamine 6G (R6G) was calculated using the 543 following formula:

$$EF = \left(\frac{I_{SERS}}{I_{bulk}}\right) * \left(\frac{N_{bulk}}{N_{surf}}\right)$$
(2)

544 Where I_{SERS} and I_{bulk} are the measured peak intensities in 545 the SERS and control Raman spectra of R6G respectively. N_{bulk} and N_{surf} are the number of molecules under laser 546 547 illumination for the bulk and SERS sample, respectively. In 548 our setup, the bulk sample is 10 mg/mL R6G water solution 549 in a cuvette with 1 mm optical path (Raman spectrum in ESI 550 Fig. S4). The laser spot is estimated as a 2 μm diameter circle, therefore N_{bulk} is roughly 4×10^{10} molecules. It is 551 552 reported that the average surface density of R6G in densely 553 packed monolayers is approximately $4 \times 10^{-11} mol/cm^2$ 554 $^{\rm 58}$, thus we estimated N_{surf} on the 2 $\mu m \times$ 2 μm array to 555 be 10⁶. Although recent work demonstrated STEM-EELS 556 could be used to map the adsorbed surface molecules⁵⁹, it is difficult to achieve for Raman dyes because these organic 557 558 molecules are known to aggregate and build up as carbon 559 contamination when exposed to an electron beam.

560 The fluorescence background of measured Raman 561 spectra were fitted as polynomial functions and 562 subsequently removed using a MATLAB script⁶⁰, before 563 extracting the peak intensities to compute the

564 enhancement factors. The script is available online at 565 https://github.com/michaelstchen/modPolyFit_

566 Hyperspectral data processing

567 EEL spectrum images were analyzed in Gatan 568 Microscopy Suite (GMS) 3 (Gatan Inc.). The reflected tail 569 method implemented in the software was used for zero loss 570 peak (ZLP) subtraction. EEL spectra were normalized with 571 respect to the ZLP maximum intensity. EELS intensities at a 572 particular energy loss were plotted in a colormap using a 573 MATLAB script. Spectrum images were imported into 574 MATLAB using a modified version of the algorithm available 575 online 576 https://www.mathworks.com/matlabcentral/fileexchange

576 https://www.matnworks.com/matiabcentral/fileexchange

578 EELS simulation

579 EELS simulations were calculated using the MNPBEM 580 toolbox³⁴ with the retarded approximation, similar to a 581 previously reported approach²⁰. These calculations utilized 582 electron beam parameters consistent with the experiment, 583 including an energy of 300 keV and a probe diameter of 0.5 584 nm. EEL spectra were calculated using an electron beam 585 positioned at similar locations as those used in the 586 experiment and with an energy step of 0.01 eV. The Au 587 nanodisc arrays were modelled as a nine disc array 588 positioned on top of a substrate layer. The number of discs 589 in the array was limited to nine because of computational 590 limitation. However, it was found that a nine-disc array was 591 sufficient for the simulation to closely match the 592 experimental observation. Additionally, increasing the 593 array size from four to nine discs had very minor effects on 594 the simulated results, suggesting that nine discs are 595 sufficient for capturing the behaviour of EELS signals from 596 these samples. The geometry of the Au disc array models, 597 for example the disc diameter and disc spacing, were 598 created to be consistent with STEM observations. The single 599 discs were generated from a 20-sided polygon positioned 600 on top of a 35 nm thick layer of SiN_X or SiO_X . Energy-601 dependent dielectric values adapted from literature were 602 used for Au⁶¹. A dielectric constant of 4.2 and 2.1 were used 603 for the SiN_x and SiO_x substrates, respectively. The bowtie 604 models were created from two triangular shaped plates 605 that had a thickness of 30 nm, a length of 100 nm, and a corner radius of 10 nm, similar to the experimentally 606 607 observed structures. The bowtie was given a 50 nm gap and 608 placed on a 35 nm thick SiN_x substrate. The surrounding 609 medium for all models used a vacuum dielectric constant of 610 1.

611 To simulate the spectral broadening caused by the 612 experimental EELS energy resolution, simulated spectra 613 were convolved with a Lorentzian function at a full width 614 half maxima between 0.13 and 0.2 eV that was measured 615 from the corresponding experimental data. Simulated EELS 616 maps, such as those shown in **Figs. 2d-e**, were calculated in 617 the area around the central disc of a 9 disc array. Then the 618 simulated map was reproduced 4 times to make it more

- 619 comparable to the experimentally mapped areas. To help 620 interpret the experimentally measured LSPR modes, the
- 620 interpret the experimentally measured LSPR modes, the 621 complex charge distribution for each mode was studied.
- 622 Both the real and imaginary parts of the complex charge
- 623 distributions were calculated for each mode, but only the
- 624 impriment part of the charge distribution is presented here
- 624 imaginary part of the charge distribution is presented here,
- 625 following previous studies^{20,62}.

626 Damped harmonic oscillator model

627 Electron energy loss ΔE can be computed from the work 628 performed by the electron against the induced electric 629 field E_{ind} ⁶³

630 $\Delta E = e \int v \cdot E_{ind}[r(t), t] dt = \int \hbar \omega \Gamma_{EELS}(R, \omega) d\omega,$

631 where v is the speed of electrons, r(t) denotes the time dependent position function and the loss probability 632 $\Gamma_{EELS}(R,\omega) = \int \mathcal{R}e\{e^{-i\omega t}v \cdot E_{ind}[r(t),\omega]\}dt$ is the work 633 634 done by electrons in Fourier space with ω being their 635 frequency. That is, the amplitude of EEL spectra is related 636 to the local induced electric field. Moreover, it has recently 637 been shown that in systems with translational invariance 638 along the direction of electron motion, the electron energy 639 loss probability is proportional to the photonic local density 640 of states⁶⁴, the property of which again has been proven to 641 be proportional to the local field intensity normalized by the 642 absorbed power⁶⁵. Considering that a damped harmonic 643 oscillator can be used to model the local field enhancement 644 in optical studies⁴⁹, we therefore use a similar approach to 645 describe the LSPR response in EELS given by

$$I(\omega) = \frac{A}{\left(\omega - \omega_p\right)^2 + \left(\frac{\Gamma}{2}\right)^2}$$
(3)

646 where $I(\omega)$ is the frequency dependent polarizability of the 647 oscillator, which we also take as the local field 648 enhancement in this context^{15,49}. A is a proportionality 649 factor, ω_p is the plasmon frequency, and Γ is the FWHM of 650 the resonance, which is a measure of the total damping of 651 the system. One of the challenges when applied in EELS is 652 the instrument broadening effects on the resonance linewidth Γ due to the non-monochromaticity of the 653 654 electron source. Here we used Olivero and Longbothum's 655 empirical approach^{52,66} by assuming the ZLP is a Gaussian 656 function and the LSPR follows a Lorentzian profile.

$$\Gamma_{\rm V} = 0.53\Gamma_L + \sqrt{0.22\Gamma_L^2 + \Gamma_G^2}$$
 (4)

657 where Γ_V is the FWHM of the convolved surface plasmon 658 peak which produces a Voigt profile, $\Gamma_{\rm G}$ is the FWHM of the 659 ZLP and $\Gamma_{\!L}$ is approximately the original surface plasmon 660 linewidth. The convolved plasmon peak was fitted into a 661 Voigt profile using OriginPro software to obtain Γ_V values. 662 (For bowties, both the bonding and antibonding dipolar 663 surface plasmon peaks were fitted and each peak was 664 analyzed separately using the same method as the following). The calculated LSPR linewidth along with the 665 resonance energy were then inserted into Equation (3) to 666 estimate the local field enhancement. Although the surface 667

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668 plasmons driven by electrons are different from those by 669 plane waves, the differences are more related to the spatial 670 distribution of hotspots^{67,68}. In our study as well as other 671 published work that correlate optical and EEL 672 spectroscopy^{69,70} where traditional hotspots are not 673 considered, the localized surface plasmon resonance for 674 disperse nanoparticles are reasonably similar in both types 675 of excitation. Therefore using Equation (1), the 676 electromagnetic SERS enhancement G can be roughly 677 estimated from EEL spectra as $I(\omega_L)I(\omega_R)$, where ω_L is the 678 laser excitation frequency and ω_R is the Raman peak 679 frequency. To directly compare the measured SERS EF and 680 the estimated G from EELS in **Fig. 5a**, a scaling constant k is 681 applied to our estimated G by minimizing the sum of the squares of the difference between measured EF and 682 683 estimated G.

684 Conflicts of interest

685 There are no conflicts to declare.

686 Acknowledgements

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Correlation of surface plasmon resonance and surface enhanced Raman scattering: maximum enhancement achieved when excitation laser match with plasmon resonance.